

[10191/4116]

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s) : LAERMER et al.
Serial No. : To Be Assigned
Filed : Herewith
For : LAYER SYSTEM HAVING A SILICON LAYER AND A
PASSIVATION LAYER, METHOD FOR CREATING A
PASSIVATION LAYER ON A SILICON LAYER AND ITS USE
Art Unit : To Be Assigned
Examiner : To Be Assigned
Confirmation No. : To Be Assigned
Customer No. : 26646

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Commissioner for Patents
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Alexandria, VA 22313-1450

**PRELIMINARY AMENDMENT AND
37 C.F.R. § 1.125 SUBSTITUTE SPECIFICATION STATEMENT**

SIR:

Please amend the above-identified application before examination, as set forth below.

Amendments to the Specification appear in page 2 of this paper and include a Substitute Specification and Marked-Up Copy attached hereto.

Amendments to the Claims are reflected in the listing of claims which begins on page 3 of this paper.

Amendments to the Drawings do not appear in this paper.

Remarks begin on page 6 of this paper.

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